## Functional behaviour of TiO<sub>2</sub> films doped with noble metals

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### Abstract

To evaluate the effects of different concentrations of noble metal in a  $TiO_2$  matrix, different films of both Ag: $TiO_2$  and Au: $TiO_2$  systems were prepared. Mechanical and tribological characterization was carried out to evaluate the coatings response as a function of the noble metals composition and (micro)structure of the films. The overall set of results indicates that the amorphous films reveal better results than the crystalline ones. For the amorphous samples, the reduced Young's modulus and the adhesion critical loads followed similar tendencies in both sets of films. Wear rates were similar for all samples except for the one with the highest silver content. To improve brittleness of  $TiO_2$  films, the results seem to indicate that a slight metal doping is preferred, and Au showed to be a better choice than Ag. In fact, the sample with the lowest Au content revealed a better mechanical behaviour than the pure  $TiO_2$  film.

**Keywords:** Magnetron sputtering; Thin films; Brittleness; Noble metal doping; Titanium dioxide **Nomenclatures / abbreviations:** 

Mole %
Poisson ratio
Silver
Argon
Atomic %
Gold
Direct Current
Reduced Young's modulus
Electrocardiography
Electroencephalography
Electromyography
Face-centered cubic
Hardness
Localised Surface Plasmon Resonance
Number of mole
nanoparticles
Physical Vapor Deposition
Rutherford Backscattering Spectrometry
Scanning Electron Microscopy
Surface-Enhanced Raman Spectroscopy
Silicon
Titanium dioxide
X-Ray Diffraction

## 1. Introduction

Titanium dioxide (TiO<sub>2</sub>) is a transparent semiconductor material, with a high bandgap, varying between 3.0 and 3.4 eV <sup>1-4</sup>. Concerning its behaviour, TiO<sub>2</sub> is known for its biocompatibility, non-toxicity, chemical stability, high hardness and high optical transmittance, combined with a high refractive index, between 2.4 and 2.9 <sup>5-10</sup>. Due to these characteristics, TiO<sub>2</sub> is widely used in

several optical devices, biomedical applications, dye sensitised solar cells, photo-electrolysis, photocatalysis, as a coating for anti-fogging and evn as a self-cleaning coating material for glasses <sup>5, 6, 11</sup>. In basic terms, TiO<sub>2</sub> exists in both amorphous and crystalline forms. Specifically, the two most important crystalline forms are anatase and rutile, both showing a tetragonal-like structure lattice <sup>12</sup>. Among these phases, anatase is known for its excellent photocatalytic activity <sup>12</sup> and it is kinetically stable at low temperatures. In the rutile form, TiO<sub>2</sub> has good structural stability at high temperatures, together with a higher refractive index <sup>13</sup>. On the other way around, in the amorphous form,TiO<sub>2</sub> has high blood compatibility and thus it is often used in several types of biomedical applications <sup>14</sup>.

Brittleness is an important feature for any kind of thin films system, which may restrict its use in some applications that require flexible substrates <sup>15-17</sup>. The case of thin film systems designed for polymeric base electrodes or sensors to be used in several types of biomedical applications, including electroencephalography, EEG, and electrocardiography ECG <sup>18</sup> and electromyography, EMG <sup>15, 19, 20</sup>, as well as some kinds of biological sensors <sup>21</sup> are particularly noticeable examples, that are being develop in the group for some time. To overcome this drawback and improve flexibility of the coated devices, the tailoring of the elastic modulus <sup>22</sup> of the thin film systems by adding silver (Ag) or gold (Au) to such oxide material, is one of the most promising routines that can be optimized. At the same time, the dispersion of such noble metals (Au, Ag) throughout the TiO<sub>2</sub> matrix can create thin films with metallic nanoparticles (NPs), responsible for the so-called localised surface plasmon resonance (LSPR) <sup>23</sup>, which gives rise to a set of unique properties that enables the film system to be used in some applications that were fristly impossible when ussing pure oxide-type films.

Furthermore, the absorption bands in the visible spectra range are the main feature associated with the presence of Au and Ag nanoparticles <sup>23</sup>. This effect can produce a palette of colours <sup>9</sup> if one can tune the LSPR position, the bandwidth and peak height through changes on the size, distribution and shape of the NPs, as well as on the host dielectric matrix (such as TiO<sub>2</sub>). Consequently, the tailoring of the optical properties of the nanocomposites is possible <sup>24-26</sup>.

Beyond colouring that was used for several centuries in the windows of the medieval cathedrals and ancient Roman glass cups, advanced applications of such plasmonic nanocomposite materials include: solar cells, optoelectronic devices, biosensors, gas sensors, magnetic storage, energy conversion, optical filters, photocatalysis and surface-enhanced Raman spectroscopy (SERS) <sup>27-35</sup>. As mentioned before, to overcome the limitation of experimental conditions, LSPR thin films have to be developed with higher robustness and flexibility in order to support mechanical stress. Taking this into account, and in order to evaluate the effects of different concentrations of Au and Ag in a TiO<sub>2</sub> matrix, several thin films of Ag:TiO<sub>2</sub> and Au:TiO<sub>2</sub> systems were produced by reactive magnetron sputtering. This physical vapour deposition technique was chosen since it is known to be an environmentally friendly coating process that provides durable materials with low-cost production, when compared to the traditional preparation methods <sup>42</sup>. The determination of hardness, reduced Young's modulus, wear rate and critical loads <sup>36-38</sup> was performed in order to evaluate the brittleness of the coatings and to correlate the mechanical behaviour with the composition and (micro)structure of the films <sup>17, 39-44</sup>.

### 2. Experimental details

The Au:TiO<sub>2</sub> and Ag:TiO<sub>2</sub> thin films were prepared by reactive DC magnetron sputtering <sup>45</sup>, on Si (Boron doped p-type, <100> orientation, thickness of 525  $\mu$ m), in a custom-made deposition system <sup>45</sup>. The system is composed of a cylindrical deposition chamber (~40 dm<sup>3</sup>), a pre-chamber, a vacuum system, a gas flow controller, an electrical system and a control unit. The deposition chamber is composed by two vertically aligned rectangular magnetrons, in a closed field configuration. To produce the films, only one magnetron was used, powered by a Hüttinger PFG 7500 DC (maximum output of 7.5 kW). The primary vacuum of the deposition chamber (with pressures of ~0.3 Pa) is achieved using a rotary vane vacuum pump, a Balzers Duo 012A. The secondary vacuum (with pressures of ~10<sup>-4</sup> Pa) is obtained using a TurboMolecular vacuum pump, model PTM 5400 (400 L.s–1) from Alcatel. To measure the gas pressure, the system is controlled by a Leybold Penningvac PTR225 (10<sup>-7</sup>–10 Pa) and a Leybold Sky-Pirani Gauge

TR090 ( $10^{-2}-10^{5}$  Pa). The films were prepared using a substrate holder positioned at 70 mm from the target, in a rotation mode-type (9 rpm). A titanium target ( $200 \times 100 \times 6 \text{ mm}^{3}$ , 99.8% purity) containing different amounts of Au, or Ag, pellets (1 mm thick and 4.5 mm in diameter) incrusted in the erosion track of the Ti target was used. The number of Au or Ag pellets was changed to vary the flux of Au or Ag atoms towards the substrate and thus obtain films with different noble metal concentrations. The power supply connected to the target was set to operate in the current regulating mode, using a current density of 100 A.m<sup>-2</sup> on the Ti-Au, or Ti-Ag, target. The films were prepared using an atmosphere composed of Ar and O<sub>2</sub> leading to a total pressure of about  $4 \times 10^{-1}$  Pa. To promote and enhance the adhesion of the films, the Si substrates were treated using an *in situ* etching process in Ar (pressure of about  $5 \times 10^{-1}$  Pa) under a pulsed DC current of 0.5 A with a duty cycle of 30%, during 1200 s. Find the etching and deposition parameters summarized in Table 1.

Parameter	Etching	Deposition	
<b>Power Source</b>	Pulsed DC Current ( $T_{on} = 1536$ ns, f = 200kHz)	DC Current	The
Ar (sccm)	70	60	dep
O <sub>2</sub> (sccm)	-	7.5	aait
Time (s)	1200	3600	osit
Current (A/m <sup>2</sup> )	25	100	ion
T (°C)	100	100	par
Bias	-	Grounded	-
P <sub>Work</sub> (Pa)	5×10 <sup>-1</sup>	4×10 <sup>-1</sup>	ame
P <sub>Base</sub> (Pa)	~10 <sup>-5</sup>	10 <sup>-5</sup>	ters,

Table 1 – Etching and deposition parameters to produce the coatings

such as the target potential and current, gas pressure, argon flow and reactive gas flows, were monitored before and during the deposition, using a Data Acquisition/Switch Unit Agilent 34970A, equiped with a multifunction module (334907A), where the cables (from analog outputs

of the power supply, pressure sensors and flow controllers) were connected. This unit uses an RS-232 interface, and the data is acquired with a Benchlink Data Logger III software.

The chemical composition of the films was determined by Rutherford Backscattering Spectrometry (RBS). Measurements were carried out using 2 MeV <sup>4</sup>He and 1.4 MeV <sup>1</sup>H beams, at normal incidence. Three detectors were employed in the chamber; one located at a 140° scattering angle and two pin-diode detectors located symmetrically to each other, both at a 165° scattering angle respective to the beam direction. The data were analysed with the code NDF <sup>46, 47</sup>.

Structural characterization of the coatings was conducted by X-ray diffraction (XRD) in a Bragg-Brentano configuration, in a Brucker D8 Advance diffractometer, operating with a CuK $\alpha$  radiation ( $\lambda = 0.154$  nm) source. The working voltage of the instrument was 40 kV with a current of 40 mA. The diffraction peaks corresponding to planes <111> and <200> were deconvoluted using the Pearson VII functions to match the peak position, peak intensity and integral breadth, using Winfit software <sup>48, 49</sup>. The grain size was estimated based on the integral breadth method, using the same software. The morphology of the films was analysed by Scanning Electron Microscopy, SEM, in an Ultra-high resolution Field Emission Gun Microscope, NOVA 200 Nano SEM from FEI Company. Secondary electron images were acquired at an acceleration voltage of 10kV.

The scratch tests were performed using a commercial scratch tester from CSM Instruments, equipped with a Rockwell indenter (Steel 100C6) with a tip radius of 100  $\mu$ m. The scratch length and speed were set to 5 mm and 5 mm/min, respectively. The load was varied between 0.03 N and 3 or 30 N, at a loading rate of 3 N/min or 30 N/min. Figure 1 demonstrates a typical scratch pattern obtained for the films under study. A brittle tensile failure can be seen starting at the arrow LC1 <sup>50, 51</sup>, representing the normal load at which the cracking of the film begins. In LC2, one can observe local interfacial spallation, while in LC3 there is a significant interfacial spallation in all track width <sup>52</sup>.

The hardness (*H*) and reduced Young's modulus of the films ( $E^* = E/(1-v^2)$ ; where *E* is the Young's modulus and v the Poisson ratio) were determined using the Oliver & Pharr Method, from the loading and unloading curves, acquired with a sensing Berkovich nanoindenter from

CSM Instruments (Switzerland), using a maximum load of 60 mN and a maximum depth around 10% of the thickness of the films. The wear rate of the coatings was estimated using a ball-on-disk tribosystem from CSM Instruments (version 4.4.K). The counterpart was an AISI 100Cr6 steel ball of 6 mm diameter. The conditions of the tests were 5 N of applied load, a speed of 5 cm/s, a track diameter of 10 mm and a temperature of 24 °C and 32% RH. The maximum number of laps (the stop condition) was 1000, and the acquisition rate was 20 Hz. The samples and the balls were cleaned with isopropanol before each wear test. Normalised wear rates were calculated after measurement of the worn track section for each sample, using a Taylor Hobson profilometer.

## 3. Results and discussion

### 3.1. Chemical, Morphological and Structural characterisation

RBS analysis revealed an O/Ti atomic ratio very close to 2, suggesting the presence of a roughly stoichiometric  $TiO_2$  matrix. Table 2 summarises the composition and thickness of the representative films, estimated by RBS and cross-section SEM analysis, respectively.

Coating	Noble metal content, (at.%)	Noble metal content, χ <sub>Au</sub> ,Ag (mole %)	Ti (at.%)	O (at.%)	O/Ti	Thickness (µm)
TiO <sub>2</sub>			34	66	1.9	0.4
Ag14	5	14	32	63	2.0	0.5
Ag46	21	46	25	54	2.1	0.7
Ag63	34	63	20	46	2.3	0.7
Ag72	39	72	15	46	3.1	2.0
Au14	5	14	31	64	2.1	0.3
Au23	9	23	30	61	2.0	0.4
Au43	20	43	26	54	2.1	0.6
Au64	37	64	21	42	2.0	0.6
Au73	46	73	17	37	2.2	0.9

Table 2 – Nobel metal contents and film thickness.

The atomic concentration of silver in the Ag:TiO<sub>2</sub> films varied from 5 to 39 at.%, while the gold concentration in the Au:TiO<sub>2</sub> films, ranged from 5 to 46 at.%. The mole percentage,  $\chi$ , of noble metal in the film – n(Au) / (n(Au) + n(TiO<sub>2</sub>)) × 100 – is also displayed in Table 2. From now on,

the films will be mentioned according to the names used in Table 2 (1<sup>st</sup> column), corresponding to the noble metal content expressed in mole % ( $\chi_{Au,Ag}$ ).

SEM micrographs displayed in Figure 2(a) show a dense and compact growth for the pure TiO<sub>2</sub> film. The columns can barely be distinguished since they are not very well defined. From this point, both systems follow different tendencies concerning their microstructure when the noble metal (Au or Ag) is added to the TiO<sub>2</sub> growing matrix. With the addition of Ag, the compact structure of TiO<sub>2</sub> is lost, changing to a more porous and disordered one. As it can be observed in Figure 2(b-d), the type of growth is granular-voided in the Ag:TiO<sub>2</sub> films and the surface appears to be very rough, which is an expected behaviour taking into account other related works <sup>15 53</sup>. In contrast, it is also clear in Figure 2(e-g) that the addition of Au kept the compact and nearly columnar structure of the TiO<sub>2</sub> intact. Only at very high contents of Au ( $\chi_{Au} \ge 64 \mod \%$ ) the results found in a recent work <sup>21</sup>. The microstructures of the Ag:TiO<sub>2</sub> is known to be higher than Au <sup>15,21,54</sup>. This higher diffusion and aggregation of silver results in the formation of Ag clusters, here demonstrated by the bright spots observed in the corresponding SEM images, Fig. 2.

The XRD patterns of representative samples with different noble metal contents are depicted in Figure 3. Only peaks related to diffraction on Au and Ag phases were detected for some noble metal concentrations, meaning that the TiO<sub>2</sub> matrix remained amorphous. Samples with higher Ag (Figure 3a) and Au (Figure 3b) contents developed a relatively clear crystalline structure. Samples with  $\chi_{Ag}$  of 63 and 72 mol % (Ag63 and Ag72) showed the typical fcc structure of Ag (ICDD card N° 04-0783) <sup>15, 53</sup>. The crystalline structure is evidenced by the presence of XRD peaks located at 2 $\theta$  positions of 38.1° and 44.3°, corresponding to <111> and <200> orientations. Therefore, the formation of crystalline silver only occurs above  $\chi_{Ag}$  of 50 mol %. In the Au:TiO<sub>2</sub> system, Au also starts to crystallise at the highest concentrations ( $\chi_{Au} > 50$  mol %), since only the films with  $\chi_{Au}$  of 64 and 73 mol % (Au64 and Au73), showed the typical fcc structure of gold (ICDD card N° 04-

0784) <sup>28</sup>. In fact, broad peaks corresponding to <111> and <200> planes located at  $2\theta = 38.2^{\circ}$  and 44.4° can clearly be observed.

According to the set of results obtained by XRD one can clearly identify two different regions in both systems: an amorphous zone for lower Ag or Au concentrations (< 50 mol %), where the existing noble atoms/clusters did not aggregate to form crystalline domains, followed by a crystalline zone where the concentration of noble metal in the film is more important. Another important feature that is worth mention is the apparent contradictory results between SEM and XRD. In fact, the sample with a silver content of 14 mol % (sample Ag14) is XRD amorphous, however, small clusters can be screened by SEM, Figure 2. This suggests that the clusters observed in Figure 2(b) are most probably amorphous. These amorphous Ag aggregates have been already reported in other works <sup>55</sup>. With the deconvolution of to XRD peak fitting (using Winfit), the average size of the crystalline silver domains was estimated to be about 18 nm, in the samples with silver contents of 63 and 72 mol % (samples Ag63 and Ag72, respectively). In the case of the two films with the highest Au contents, the grain size was estimated to be below 5 nm, revealing a significant grain size reduction. These results demonstrate, once again, silver aggregate easier into clusters, if compared to gold.

#### 3.2. Mechanical Properties

Figure 4 depicts the hardness (*H*) and reduced Young's modulus (*E*\*) as a function of the noble metal mol % ( $\chi$ ) in each identified zone (amorphous and crystalline, accordingly with the structural analysis). For the TiO<sub>2</sub> film, the hardness and the reduced Young's modulus showed values of 11 GPa and 166 GPa, respectively, which are in agreement with the values found in several published works <sup>56-58</sup>. From Figure 4 one can observe that for the film with the smallest Au concentrations, the hardness and reduced Young's modulus was higher than the TiO<sub>2</sub> film. However, these values are tendentiously lower when both Au and Ag contents are above 14 mol %, in comparison with the pure host matrix (TiO<sub>2</sub>).

The increase of the Au contents led to a gradual decrease of hardness in both amorphous and crystalline zones. From the amorphous to the crystalline zone, the variation of the reduced Young's modulus is not significant for the Au: $TiO_2$  system. The addition of Ag led to a decrease of the hardness in the amorphous zone, decreasing further when the samples became more crystalline. Concerning the reduced Young's modulus, a small increment was observed in the amorphous zone. However, this parameter decreased sharply on moving to the films indexed to the crystalline zone. This decline in hardness is most likely due to the higher ductility that gold and silver are introducing in the doped  $TiO_2$  coating <sup>58</sup>, demonstrating an important feature of this thin films systems if one intends to use them in flexible-like applications such as those mentioned in the biomedical field.

In order to evaluate the flexibility of the coatings <sup>59</sup>, the ratio between hardness and reduced Young's modulus,  $H/E^*$ , was calculated, and the results are presented in Table 3. In comparison to TiO<sub>2</sub>, one can report that the ratio  $H/E^*$  is approaching 0.1 in the films with gold contents of 14, 23 and 43 mol % (samples Au14, Au23 and Au 43, respectively), correpsonding to the films indexed to the amorphous Au:TiO<sub>2</sub> zone. This is again a clear indication of increasing flexibility <sup>59</sup>. Nonetheless, this trend is not observed for the crystalline Au:TiO<sub>2</sub> samples and for the whole series of Ag:TiO<sub>2</sub> films since the  $H/E^*$  values are decreasing in comparison to TiO<sub>2</sub> film.

Coating	H (GPa)	H/E* (×10 <sup>-2</sup> )
TiO <sub>2</sub>	11	6.6
Ag14	7.2	5.1
Ag46	3.3	2.2
Ag63	3.7	3.9
Ag72	1.4	2.3
Au14	13.1	7.2
Au23	10.8	7.3
Au43	10.3	7.0
Au64	8.3	5.2
Au73	6.1	4.1

Table 3 – Hardness of the films and the ratio between hardness and reduced Young's modulus

The cohesion of the films and their adhesion to the substrates are also essential for the needed functionalities. Figure 5 displays the critical loads as a function of the noble metal mol %. All three critical loads (LC1, LC2 and LC3) have similar tendencies in both systems. Their values increase when a small content of noble metal is added to the pure  $TiO_2$  film (less than 50 mol % of Ag or Au). In the crystalline zone, the critical loads decrease to values even lower than those of the reference critical load values of  $TiO_2$  film.

The wear rate of the samples as a function of Ag or Au content is shown in Figure 6. The plot shows that the best wear behaviour is provided by the samples with lower noble metal concentrations, indexed to the amorphous zone. In the crystalline zone, the addition of Au does not significantly affect the wear rate, always remaining below the TiO<sub>2</sub> film. The wear rate of the Ag:TiO<sub>2</sub> films indexed to the crystalline zone is also relatively low. Nevertheless, the sample with the highest Ag content reveals an increase of one order of magnitude in this tribological parameter. This sample also showed a very low adhesion and the worst mechanical behaviour, probably due to the low shear strength of silver (in higher amounts) that is segregated to the thin film surface <sup>15, 60</sup>. Another plausible explanation for the high wear rate of this sample is that the Ag particles may agglomerate and cause abrasive wear. In fact, as reported in a previous work from C.P. Twist et al. <sup>61</sup>, some Ag aggregates might produce a scar in the wear track and thus affecting the wear mechanisms.

### 4. Conclusions

In order to investigate the influence of Ag or Au doping in the brittleness of a TiO<sub>2</sub> matrix, several thin films of Ag:TiO<sub>2</sub> and Au:TiO<sub>2</sub> were successfully produced by reactive DC magnetron sputtering, using a titanium target and only a few noble metal pellets. The noble metal concentration for the two sets of films, Ag:TiO<sub>2</sub> and Au:TiO<sub>2</sub>, ranged from 14 to 72 mol % Ag and from 14 to 73 mol % Au, respectively. The structural and morphological analysis of the films showed significant differences in the structural evolution during film growth. The XRD analysis showed amorphous samples for metal concentrations of Ag ( $\chi_{Ag}$ ) up to 46 mol % and Au ( $\chi_{Au}$ ) up

to 43 mol % and, for higher noble metal concentrations, crystalline phases of Ag ( $\chi_{Ag} \ge 63 \text{ mol }\%$ ) and Au ( $\chi_{Au} \ge 64 \text{ mol }\%$ ) could be detected. While the addition of Au to the growing TiO<sub>2</sub> matrix kept the compact and columnar type of growth almost unchanged, the increase in Ag in the matrix induces the formation of Ag clusters and porous microstructures.

In terms of functional behaviour, the crystalline films have, in general, worse adhesion, mechanical and tribological properties than the amorphous coatings. Comparing the two systems, it was possible to conclude that for similar mol % of noble metal (Ag, Au) the mechanical properties of the Au doped  $TiO_2$  are, in general, better than the Ag doped  $TiO_2$ , also confirmed by analysing the ratio  $H/E^*$ . Regarding adhesion, the distinction between the two systems is not clear, only the sample with the smallest content of gold exhibits a much higher adhesion. For the wear rates, similar values were obtained, but gold doping is generally better.

A major important result is that the sample with the lower Au content ( $\chi_{Au} = 14 \text{ mol }\%$ ) revealed the best functional performance under the performed tests, being the only one that improved the mechanical properties of the host matrix (TiO<sub>2</sub>). Therefore, one can conclude that to improve the brittleness of TiO<sub>2</sub> films, to be used on flexible substrates such as polymeric electrodes and sensors, slight doping is preferred, and Au is preferable than Ag in terms of performance.

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## **Figure captions**

Figure 1 – Example of a typical scratch test performed in the films, indicating LC1, LC2 and LC3 according to optical confirmation. The debris at the coating surface as small pieces of the film that were removed as a consequence of the tip scratch in the coating surface.

Figure 2 - SEM cross-section micrographs of (a)  $TiO_2$ ; (b – d) Ag:TiO<sub>2</sub> and (e – g) Au:TiO<sub>2</sub> films.

Figure 3 - XRD diffractograms of (a) Au:TiO<sub>2</sub> and (b) Ag:TiO<sub>2</sub>.

Figure 4 – Hardness (a) and reduced Young's modulus (b) of the films as a function of the noble metal mole %.

Figure 5 - Critical Loads (LC1, LC2 and LC3) as a function of the (a) Ag mole % and (b) Au mole %.

Figure 6 - Wear Rate of the films as a function of noble metal mole %.

# **Table captions**

- Table 1 Etching and deposition parameters to produce the coatings
- Table 2 Nobel metal contents and film thickness.
- Table 3 Hardness and reduced Young's modulus ratio

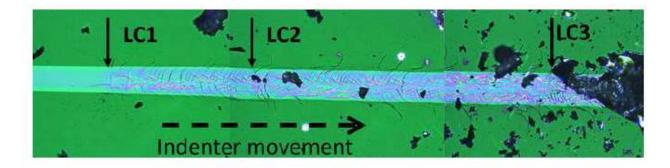
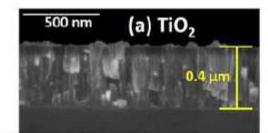


Figure 1



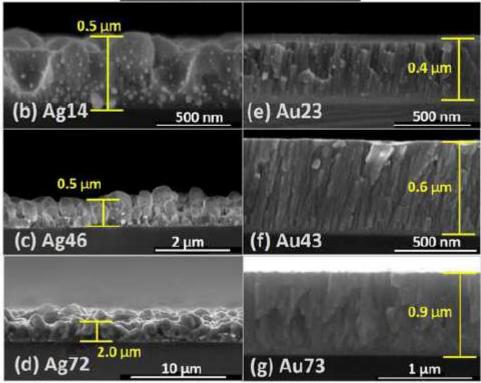


Figure 2

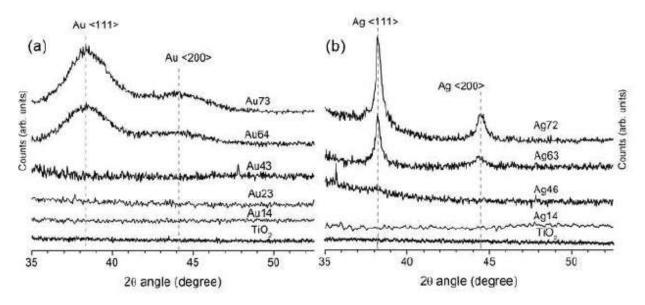


Figure 3

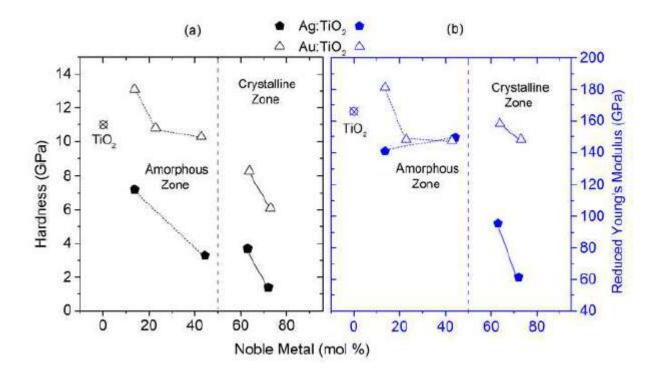


Figure 4

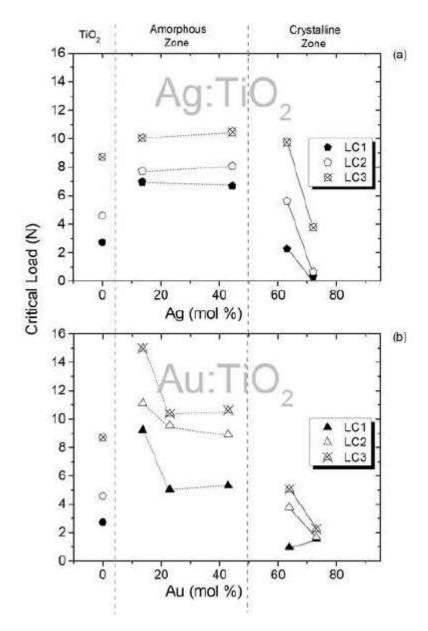


Figure 5

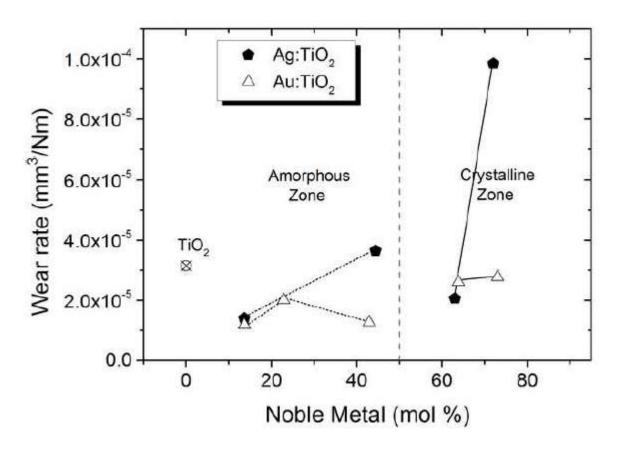


Figure 6